

Title (en)  
Charge plate fabrication process

Title (de)  
Verfahren zur Herstellung von Ladungselektroden

Title (fr)  
Procédé de fabrication d'électrodes de charge

Publication  
**EP 0744290 A2 19961127 (EN)**

Application  
**EP 96303395 A 19960514**

Priority  
US 45232695 A 19950526

Abstract (en)

A charge plate fabrication process uses conventional methods to fabricate the charge plate. Initially, a non-conductive charge plate substrate is provided, the substrate having an edge and a top. The substrate is then edge patterned to define a charging face on the edge of the non-conductive charge plate substrate. The conductive path from the charging face to the top of the non-conductive charge plate substrate is completed to create a charge plate. The charge plate is then top patterned. <IMAGE>

IPC 1-7  
**B41J 2/085**

IPC 8 full level  
**B41J 2/085** (2006.01)

CPC (source: EP)  
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Cited by  
US6478413B1; US7163281B2; WO2005108089A1; US8104170B2

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